

ABM UV Flood Exposure System - Sunny - HA

Equipment	ABM UV Flood Exposure System - Sunny
Process Area	LITHOGRAPHY
Location	Primary Lithography, Cleanroom (W1-062 ECERF)
Assessed By	Breanna Cherkawski
Date of Assessment	01 Mar 2024
Final Assessment	MEDIUM



Please Review

Carefully review and familiarize yourself with the hazard assessment applicable to your tool or process.